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利用課題名(日本語)	:ナノフォーム
Program Title (English)	: Nanofoam
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キーワード/Keyword	:形状・形態観察、分析、Nanocellular

<u>1. 概要(Summary)</u>

In this project, we have investigated the cell structure of nanocellular foams using the SEM at Nanohub. Thin films of PMMA-b-PtBA were prepared by solution casting. Nanocellular foams were created within the thin film by UV-induced chemical foaming, where isobutene is created from side chain cleavage of the polymer. The effects of the polymer specifications on the cell structure was studied

<u>2. 実験(Experimental)</u>

【利用した主な装置】

超高分解能電界放出形走査電子顕微鏡, 走査型プロー ブ顕微鏡システム, 分光エリプソメーター

【実験方法】

The self-assembled morphology was observed by SEM with 10 kV accelerating voltage and 1 μ A electron current. Prior to the measurement, the approximately 1 nm of Pt was spluttered on the sample.

<u>3. 結果と考察(Results and Discussion)</u>

The effect of the polymer specification on the UV-induced chemical foaming process was studied. In this experiment PMMA-b-PtBA films with PMMA:PtBA of 1:1 with $M_n = 73800$, 117300 and 233200 were casted with 5 wt% PAG. Self-assembled lamella morphologies with b = 40, 70 and 130 nm were obtained. The films were foamed by a UV-induced chemical foaming process at UV dosage of 3600 mJ/cm² and heating at 80 °C for 5 minutes. The SEM images of the nanocellular foams are summarized in Figure 1.

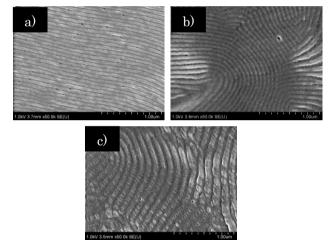


Fig. 1 SEM images of nanocellular foams from PMMA-b-PtBA with M_n of (a) 73800, (b) 117300 and (c) 233200.

<u>4. その他・特記事項(Others)</u>

論文 [1] P. Rattanakawin et al., J PHOTOPOLYM SCI TEC **31(5)**, 2018, 647

[2] P. Rattanakawin et al., J PHOTOPOLYM SCI TEC 32(5), 2019, 693

[3] P. Rattanakawin et al., ACS MACRO LETT.9(10), 2020, 1433

学会発表 [1] P. Rattanakawin et al., FOAMS 2019 (October 2-3, 2019, Valladolid, Spain)

5. 論文·学会発表(Publication/Presentation) なし。

<u>6. 関連特許(Patent)</u>なし。